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SPUTTER DEPOSITION OF POROUS NANOSTRUCTURED METALS AND NANOSTRUCTURED MEMBRANES FOR CATALYSIS

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Introduction

The sputter deposition process can be used to create *nanostructured* materials that possess continuous open porosity. Characterization of sputter deposited metals and metal-oxide coatings are presented.

Part 1 – Porous *Nanostructured* Metals

Porous films are of interest in several electrochemical systems, as in polymer exchange membrane and solid-oxide fuel cells. Thin film fuel cells by *microfabrication* processes have progressed to demonstration.[1,2] Porous thin films are used to reform hydrocarbon fuels and to function as conductive electrodes. For catalytic functions, in particular, the control of a three-dimensional structure at the *nanoscale* provides the means to produce materials with an ideal surface area to volume ratio. A ratio much greater than found in materials as produced by either conventional powder processing or as produced using photolithographic patterning and etching.[3]

Recently, a physical vapor deposition method has been developed to produce metallic films with continuous open porosity at the *nanoscale*.[4] The experimental parameters needed to control the porous *nanostructure* are found to be tractable and generic for many metals. In general, structural morphologies found for conventionally sputtered coatings can range from porous columnar to dense polycrystalline. The transition in morphology through four zones of growth occurs with increasing substrate temperature and sputter gas pressure. Zone 1 has a structure consisting of tapered crystallites separated by voids. A transition Zone T has a structure consisting of densely packed fibrous grains and a smooth surface. Zone 2 features continuous columns from the substrate to a surface characterized by crystalline facets. Lastly, Zone 3 represents the recrystallized grain structure. The primary effect of increased temperature is an enhancement of surface and bulk diffusion.

A new growth zone for the stabilization of a porous *nanostructure* is seen as a variant of Zones T and 2.[4] A three-dimensional polycrystalline deposit with continuous open porosity is produced under the general conditions of an increased working gas pressure and a substrate temperature approximately half the absolute melting point. The open-porosity morphology is demonstrated in as-deposited *nanostructures* of nickel.[4] New results are presented for copper – a base metal used in several catalytic materials for the direct reformation of

methanol. The use of a moderate sputter gas pressure and an elevated substrate temperature yields a nanostructured metal with open porosity, i.e. a *metallic sponge*. The moderate sputter gas pressure creates a range of incident angles for deposition and the elevated temperature promotes a faceted crystalline growth. Results for a 5 μm thick copper coating are seen in plan view (Figs. 1-2) and cross-section (Figs. 3-4). Of interest, is the coarsening in grain size that occurs from the substrate through the cross-section to the surface.

Part 2 – Nanostructured Membranes for Catalysis

Porous films in the form of *nanostructured* membranes are of interest in several electrochemical systems, as for use as electrodes in polymer exchange membrane and solid-oxide fuel cells. Over the past decade, solid-oxide fuel cells produced by sputter deposition as thin film layered structures [2,5] have progressed from a one milliamp output at 300 °C to demonstration as *microfuel* cell devices [6] capable of providing an output power at 600 °C of several hundred milliwatts per square centimeter. More recently, sputter-deposited porous membranes have generated interest for use in *microfuel* cells as electrodes [4,6] (Fig. 5) and as catalysts to reform hydrocarbons as methanol.

Nanostructured membranes for catalytic functions, in particular, require optimization of a three-dimensional structure to provide functional materials with an ideal surface area to volume ratio. The *nanostructured* membrane can potentially yield a much greater ratio than found in materials as produced by either conventional or unconventional powder processing [5] or as produced by using photolithographic patterning and etching [2]. Recently, through the development of a physical vapor deposition method [4], metallic membranes have been produced with continuous open porosity at the *nanoscale*. The experimental parameters needed to control the porous *nanostructure* are found to be tractable and generic for many metals including gold, silver, nickel, and aluminum.[4]

The result presented for depositing porous *nanostructured* copper (Fig. 4) provides the basis for synthesizing copper alloys that are of interest for use as catalytic materials. Specifically, copper-zinc-oxide is a known oxide compound widely used for the direct reformation of hydrocarbon fuels at low temperatures. A porous *nanostructure* is found in a several-micron thick copper-zinc-oxide coating, sputter deposited from a

copper-zinc alloy target using a partial pressure of oxygen, as shown in a scanning electron microscopy (SEM) image (Fig. 6). The analysis of an energy dispersive spectrometry (EDS) scan that corresponds with this coating reveals the composition to be Cu-19%Zn-14%O.

Summary

Sputter deposition is a method used to prepare *nanostructured* metals and membranes with continuous open porosity. Examples are shown in applications as electrode and as catalytic membranes for energy conversion *microdevices*. This work was performed under the auspices of the U.S. Department of Energy by the University of California, Lawrence Livermore National Laboratory under contract No. W-7405-Eng-48.

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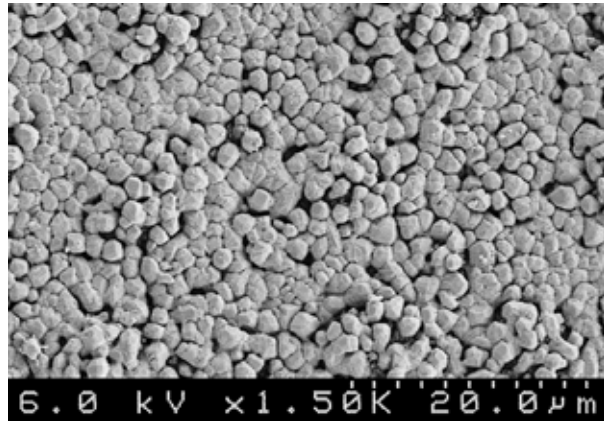


Fig. 1. The plan view image of copper produced from deposition at high temperature and sputter gas pressure.

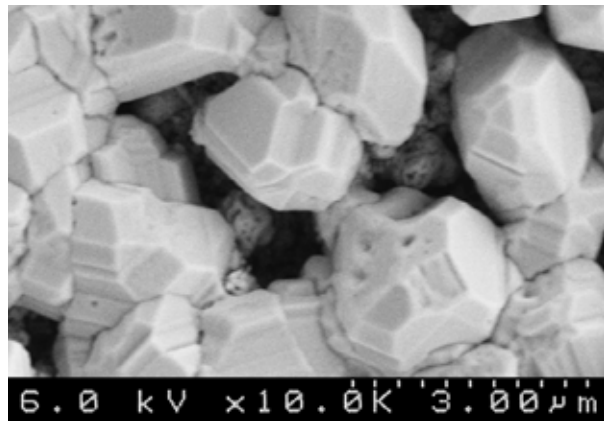


Fig. 2. A high-magnification plan view image (of Fig. 1) shows the open porosity of the porous copper coating.

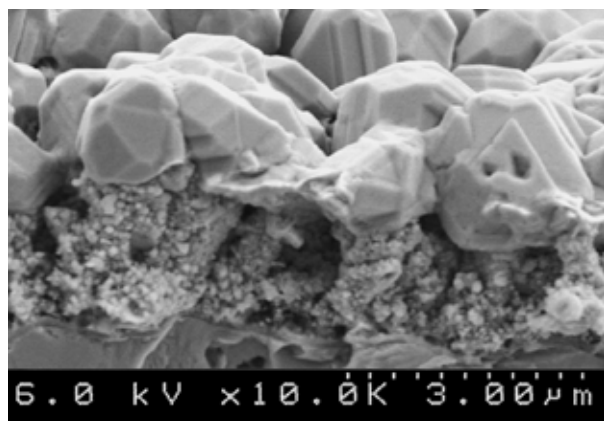


Fig. 3. A fracture cross-section shows the coarsening in crystal size through the porous copper coating.



Fig. 4. A higher magnification view (of Fig. 3) reveals the porous assembly of copper nanocrystals that forms at the base of the sputter deposited coating.

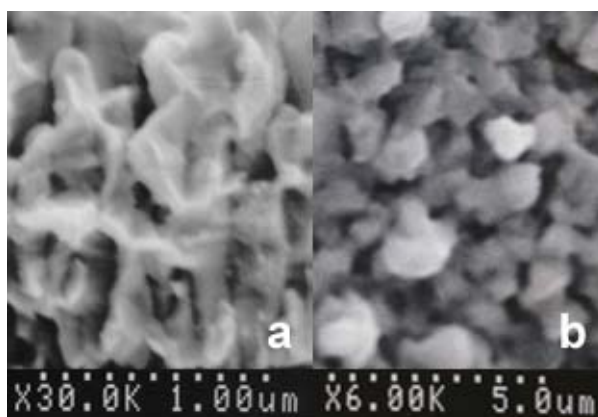


Fig. 5. SEM images of porous electrodes of (a) Ni, viewed in cross-section, and (b) Ag, in plan view, that were deposited at high temperature and sputter gas pressure.

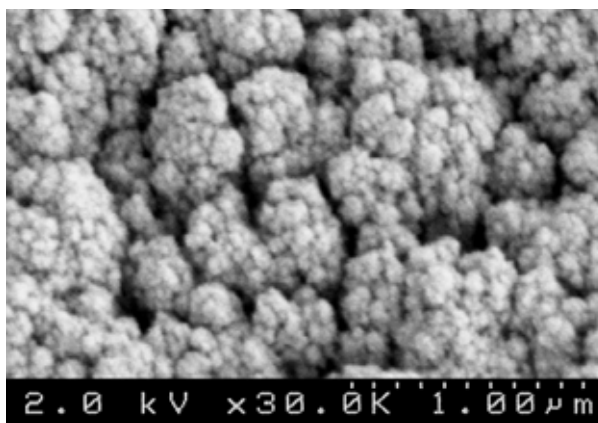


Fig. 6. SEM image of a Cu-Zn-O porous membrane, in plan view, that was reactively sputter deposited for use in catalytic hydrocarbon reformation.



Sputter deposition of nano structured porous membranes

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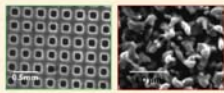
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Porous films in the form of *nano* structured membranes are of interest for many electrochemical applications. The sputter deposition process is used to synthesize *nano* structured materials that feature continuous open porosity in three-dimensions and yield an ultra-high surface area to volume ratio. Applications of *nano* structured membranes in polymer and solid-oxide fuel cells include use as electrodes and for catalytic reformation of liquid hydrocarbons.

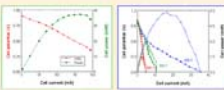
Background

- The development of porous electrodes enabled the demonstration of a MEMS-based thin-film fuel cell.
- A goal for hydrocarbon reformation integrated with the anode support motivated further investigation of non-planar porous structures.



Electrodes can be microfabricated by *pattern and etching* or by *direct deposition* as a sponge-like form.

Architecture of the thin-film fuel cell



Fuel Cell Demonstration

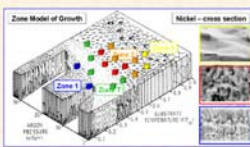
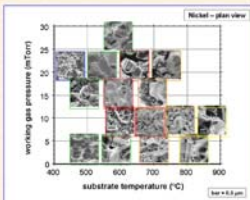
- testing with air and 2-6 sccm 4% H₂ flow
- 37 mW/cm² output of a 1 cm x 5 cm PEMFC at 60 °C
- 145 mW/cm² output of a 2 mm x 5 cm SOFC at 600 °C

Advantages and Challenges

- loading of power and low operation temperature
- low costs for materials and fabrication
- design of cell insulation and thermal budget
- fuel storage and in-situ reformation

Sputter deposition of nano structures

Deposition of metals with continuous & open 3-D porosity occurs at substrate temperatures that are half the melt point (to promote faceted growth) using a moderate sputter gas pressure (to create a range of incident angles).



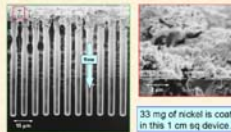
The "classic" growth model - revised

- Zone 1 - tapered crystallites separated by voids
- Zone 2 - "transition" structure of densely packed fibrous grains and a smooth surface
- Zone 3 - "sponge like" with continuous and open porosity
- Zone 4 - columnar grains with faceted surface
- Zone 5 - re-crystallized grain structure

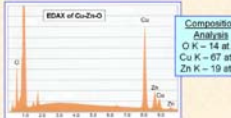
Nano structured membranes for catalysis

- The use of porous nano structured membranes is demonstrated in thin-film fuel cell electrodes. The *in-situ* reformation of liquid hydrocarbon fuels as methanol is investigated using these porous membranes in a flow through mode.
- From the understanding gained of the sputter deposition process for synthesizing *metallic sponges*, application is now furthered for the reactive deposition of catalytic compounds as copper-zinc-oxide in the form of membranes.

Reformation of liquid hydrocarbons



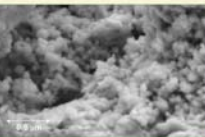
- A porous coating of nickel is sputter deposited onto and into an *anode-type* support layer.
- The fracture cross-section reveals pores in this *nickel* coating that range in size from 10¹ to 10² nm.
- The coating is approximately 40% porous by volume.
- The reaction: CH₃OH + H₂O is reformed to CO₂ + 3H₂
- A 35-44% conversion efficiency is measured by a sampling analysis of the gas products.
- For comparison, 50 mg of a commercial-grade copper-zinc-oxide catalyst should and does steam reform 73% of a ~1 ml-hr⁻¹ flow at 275 °C (and 100% at 0.33 ml-hr⁻¹).
- The two materials perform at a near equivalent level as quantified by percent conversion per milligram.



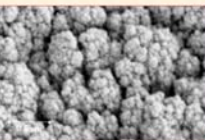
Composition Analysis

O K - 14 at %
Cu K - 67 at %
Zn K - 19 at %

Catalysts with complex chemistry



The nano structure of this porous copper coating (as viewed in cross-section) was deposited at 40% of its melt point using a 5 mTorr gas pressure of argon.



The nano structure of this porous copper-zinc-oxide coating (observed in plan view) was deposited at 40% of the melt point of the copper - 30% zinc base alloy using a 5 mTorr working gas pressure of an argon - 10% oxygen mixture. A 15 kV electron beam generates characteristic x-rays in the energy spectra for quantitative analysis using the ZAF correction.

Acknowledgment and References

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